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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/813,538	03/30/2004	Daisaku Haoto	CU-3660	5324
26530 LADAS & PAF	7590 03/18/200 RRY LLP	8	EXAMINER	
224 SOUTH M	ICHIGAN AVENUE		SPEER, TIMOTHY M	
SUITE 1600 CHICAGO, IL 60604			ART UNIT	PAPER NUMBER
			1794	
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)
	10/813,538	HAOTO ET AL.
Office Action Summary	Examiner	Art Unit
	TIMOTHY M. SPEER	1794
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with the c	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING Description of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication.  If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION  .136(a). In no event, however, may a reply be tired will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	N. nely filed the mailing date of this communication. ED (35 U.S.C. § 133).
Status		
1) ☐ Responsive to communication(s) filed on 12 L 2a) ☐ This action is <b>FINAL</b> . 2b) ☐ This action is <b>FINAL</b> .  3) ☐ Since this application is in condition for allowated closed in accordance with the practice under	is action is non-final. ance except for formal matters, pro	
Disposition of Claims		
4) ☐ Claim(s) 1-21 is/are pending in the application 4a) Of the above claim(s) 4-9,17 and 18 is/are 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-3, 10-16 and 19-21 is/are rejected 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/o	e withdrawn from consideration.  or election requirement.	
10) ☐ The drawing(s) filed on is/are: a) ☐ acceptable Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) ☐ The oath or declaration is objected to by the E	e drawing(s) be held in abeyance. Section is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document application from the International Bureat*  * See the attached detailed Office action for a list.	nts have been received. nts have been received in Applicat ority documents have been receive au (PCT Rule 17.2(a)).	ion No ed in this National Stage
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO/SB/08)  Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:	ate

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## **DETAILED ACTION**

#### Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 12/12/07 has been entered.

# Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-3 and 19-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sugimoto (US 2002/0093825) in view of Olson (USPN 6,541,591).
- 4. Sugimoto teaches EL devices comprising a silicon oxynitride film formed on a resin substrate. Sugimoto teaches various ratios for the components of the oxynitride film, but fails explicitly to teach the ranges recited in instant claim 1. However, where, as here, the prior art teaches the general conditions of a claimed invention, it is not inventive to discover optimum or workable ranges through routine experimentation. In the present case, applicant has merely altered the proportions of the film components in a routine manner and, accordingly, such endeavor is considered to be prima facie obvious in view of Sugimoto.

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5. Additionally, Sugimoto fails to teach that the substrate or the top surface of the film layered body on which the protective coat is coated is selected from the group consisting of acrylic UV curable resins, polyethylene naphthalate and polyethersulfone, as recited in the newly amended claims. Sugimoto teaches that the substrates may be formed resins, such as polycarbonate (see paragraph [0031]). Olson teaches that polyethylene naphthalate is a functional equivalent of polycarbonate as a base layer in optical products (see col. 3, lines 9-31, for instance). Therefore, it would have been obvious to one having ordinary skill in the art to employ polyethylene naphthalate as the substrate of Sugimoto, since Olson teaches that polyethylene naphthalate is a functional of the polycarbonate substrate explicitly disclosed by Sugimoto.

- 6. Regarding claims 19-21, as discussed above, Sugimoto in view of Olson renders obvious the claimed ratio of the film constituents as well as the substrate materials. With respect to the process limitations recited therein, these limitations are not considered to distinguish over the applied prior art, since applicant has failed to demonstrate that the recited process step produces a product which is materially different than the applied prior art. Applicant is claiming a product and not a process.
- 7. Claims 1-3, 10-16 and 19-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tazawa (US 2002/0043929) in view of Olson (USPN 6,541,591).
- 8. Tazawa teaches EL devices comprising first and second layers formed on a resin substrate (abstract). The layers may be formed of such materials as silicon oxide, silicon nitride and silicon oxynitride (see paragraph [0057]-[0059]). Moreover, Tazawa teaches that the materials of one layer, e.g., SiON, is a functional equivalent of components of other layers, e.g.,

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alumina (id.). Therefore, it would have been obvious to employ the presently claimed materials in the structure of Tazawa, since Tazawa suggests the use of such materials. Moreover, to modify the relative amounts of a component in the films, e.g., Si, O, and N, would have been obvious to one having ordinary skill in the art since, where the prior art teaches the general conditions of a claim, it is not inventive to discover optimum or workable ranges through routine experimentation. Therefore, it is the Examiner's position that the present claims are prima facie obvious in view of Tazawa.

- 9. Additionally, Tazawa fails to teach that the substrate or the top surface of the film layered body on which the protective coat is coated is selected from the group consisting of acrylic UV curable resins, polyethylene naphthalate and polyethersulfone, as recited in the newly amended claims. Tazawa teaches that the substrates may be formed resins, such as polycarbonate (see paragraph [0075]). Olson teaches that polyethylene naphthalate is a functional equivalent of polycarbonate as a base layer in optical products (see col. 3, lines 9-31, for instance). Therefore, it would have been obvious to one having ordinary skill in the art to employ polyethylene naphthalate as the substrate of Tazawa, since Olson teaches that polyethylene naphthalate is a functional of the polycarbonate substrate explicitly disclosed by Tazawa.
- 10. Regarding claims 19-21, as discussed above, Tazawa in view of Olson renders obvious the claimed ratio of the film constituents as well as the substrate materials. With respect to the process limitations recited therein, these limitations are not considered to distinguish over the applied prior art, since applicant has failed to demonstrate that the recited process step produces a product which is materially different than the applied prior art. Applicant is claiming a product and not a process.

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# Response to Arguments

11. Applicant's arguments filed 12/12/07 have been fully considered but, with respect to the newly added limitations regarding the substrate material, are moot in view of the new grounds of rejection. Regarding applicant's arguments with respect to the Si, O and N ratios, the Examiner maintains the position set forth in the Final Office Action dated 06/14/07. Those arguments are fully incorporated herein by reference. The provisional double patenting rejection set forth in the Final Office Action dated 06/14/07 is withdrawn, since Application No. 10/755,931 has been abandoned.

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to TIMOTHY M. SPEER whose telephone number is (571)272-8385. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Keith D. Hendricks can be reached on 571-272-1401. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Timothy M. Speer/ AU 1794